

# **How the Semiconductor Transition Metal Dichalcogenides Replaced Graphene for Enhancing Anticorrosion**

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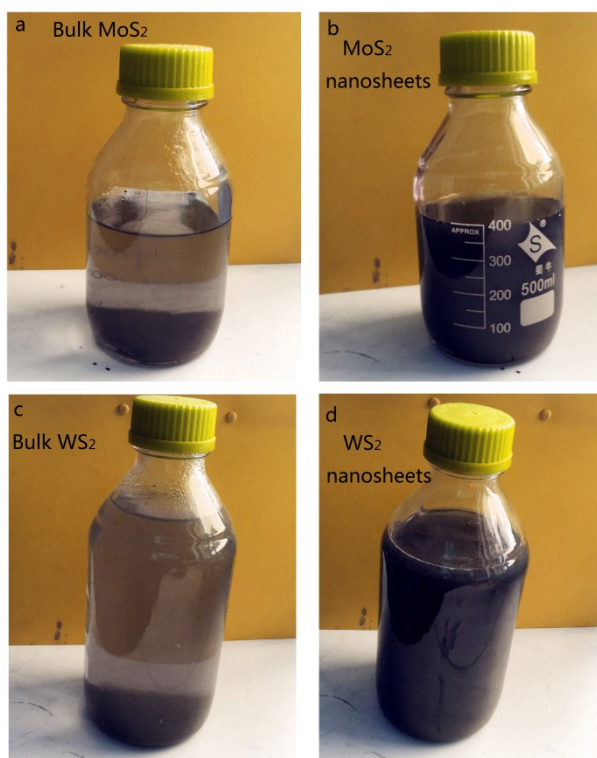
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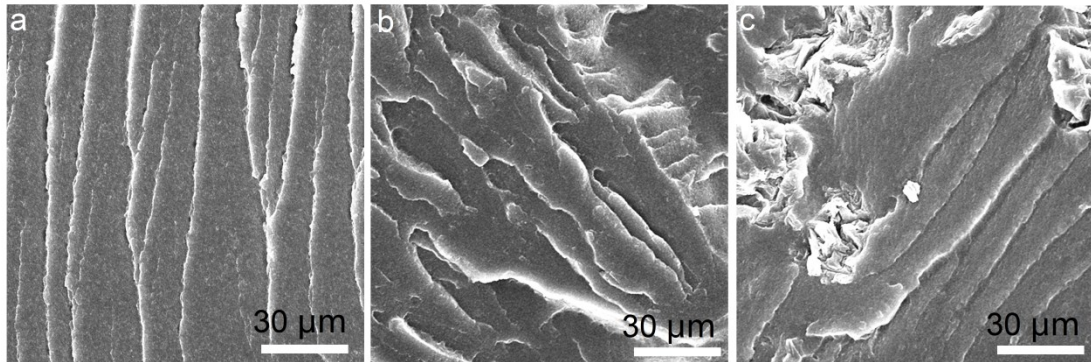
<sup>§</sup> Jiheng Ding and Hongran Zhao contributed equally to this work.

**Table S1.** Chemical composition (wt %) of the Q235 used.

Element	<b>B</b>	<b>C</b>	<b>O</b>	<b>Si</b>	<b>Cr</b>	<b>Mn</b>	<b>Fe</b>
Weight%	0.56	5.60	0.45	0.26	0.02	0.43	Bal.

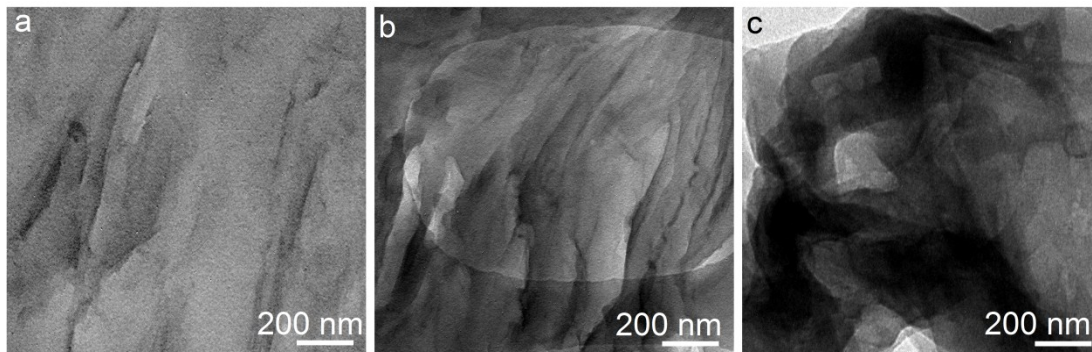


**Figure S1.** Photos of bulk TMDs and TMDs nanosheets dispersed in NMP for one week.



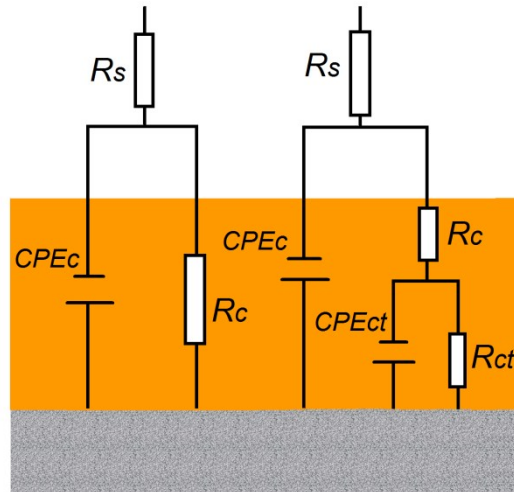
**Figure S2.** SEM images of pure EP (a), 1.0 wt.% MoS<sub>2</sub>/EP (b), and 1.5 wt.% MoS<sub>2</sub>/EP (c) coatings, respectively.

The compatibility between the MoS<sub>2</sub> nanosheets and EP matrix was observed by SEM measures of fracture surfaces for different coating systems. For EP coating (Figure S2a), the sample shows obvious brittle fracture with some holes. In Figure S2b, the addition of 1.0 wt.% MoS<sub>2</sub> into EP matrix resulted in rougher fracture surface with sparse and smooth cracks. With the loading of MoS<sub>2</sub> up to 1.5 wt. %, the cross section of the EP matrix formed more holes and messy cracks owing to the aggregated MoS<sub>2</sub> nanosheets.



**Figure S3.** TEM images of 1.0 wt.% MoS<sub>2</sub>/EP (a, b) and 1.5 wt.% MoS<sub>2</sub>/EP (c) coatings, respectively.

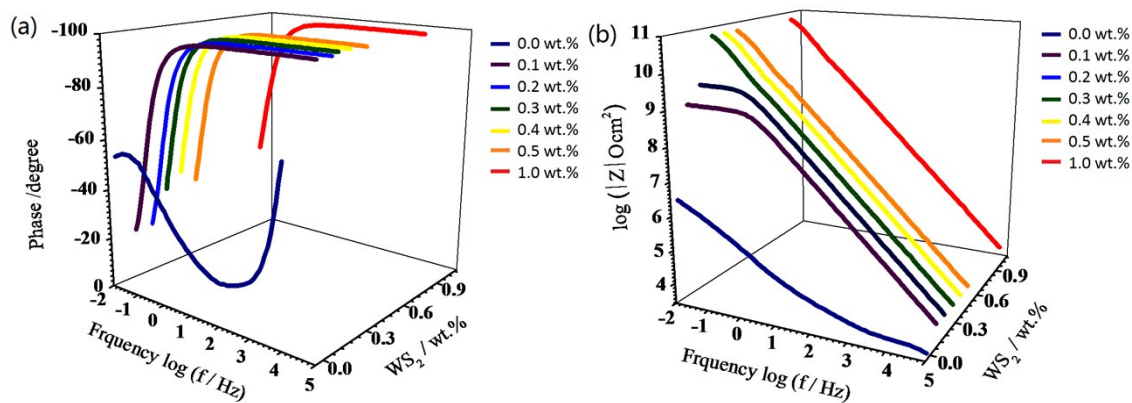
TEM were used to investigate the dispersion state of MoS<sub>2</sub>. The TEM images of MoS<sub>2</sub> dispersed in the EP matrix are shown in Figure S3. It is noted that the gray areas represent the domain of the EP matrix, while the dark lines are the profile of MoS<sub>2</sub> nanosheets. It is clearly observed that the 1.0 wt.% of MoS<sub>2</sub> nanosheets evenly dispersed in the EP matrix (Figure S3a, b). Conversely, serious aggregation of 1.5 wt.% of MoS<sub>2</sub> nanosheets is observed due to the excessive addition. These results confirmed that MoS<sub>2</sub> nanosheets can be dispersed in the EP matrix through a ball milling treatment when the addition of MoS<sub>2</sub> nanosheets was less than 1.0 wt.% .



**Figure S4.** Equivalent electrical circuits.

**Table S2.** Electrochemical parameters of MoS<sub>2</sub>/EP coatings

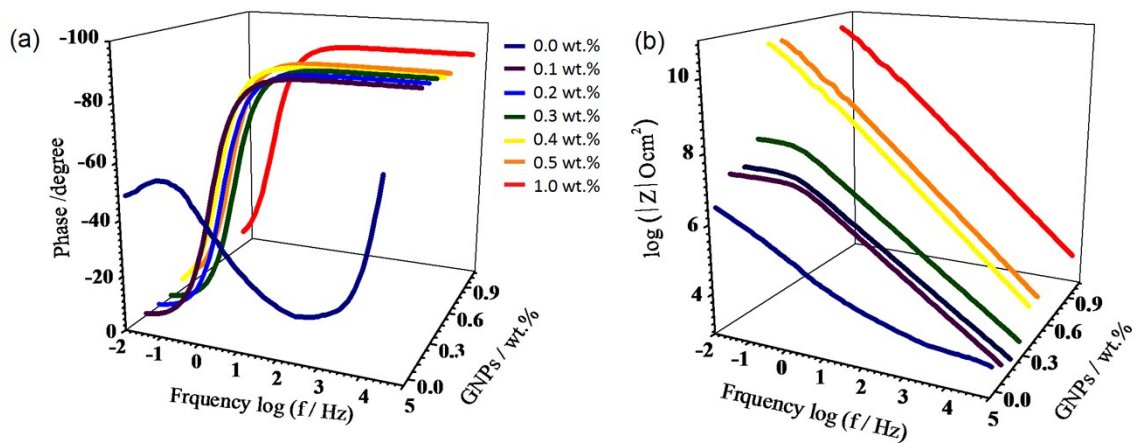
MoS <sub>2</sub> wt. %	$R_s / \Omega \text{ cm}^2$	$C_c / 10^{-10} \text{ F cm}^{-2}$	$R_c / 10^{10} \Omega \text{ cm}^2$	$C_{dl} / 10^{-4} \text{ F cm}^{-2}$	$R_{ct} / 10^6 \Omega \text{ cm}^2$
0	$25.4 \pm 3.4$	$98.9 \pm 7.8$	$3.3 \pm 0.4 \times 10^{-5}$	$8.76 \pm 0.35$	$3.56 \pm 0.33$
0.1	$20.6 \pm 2.6$	$39.4 \pm 5.6$	$0.89 \pm 0.04$	-	-
0.2	$27.2 \pm 1.9$	$32.1 \pm 5.3$	$0.96 \pm 0.03$	-	-
0.3	$26.2 \pm 5.1$	$11.4 \pm 3.3$	$1.22 \pm 0.20$	-	-
0.4	$19.4 \pm 2.4$	$9.3 \pm 1.2$	$7.5 \pm 0.23$	-	-
0.5	$21.4 \pm 1.7$	$7.8 \pm 2.1$	$7.9 \pm 0.31$	-	-
1.0	$27.4 \pm 1.1$	$7.3 \pm 1.9$	$8.1 \pm 0.24$	-	-



**Figure S5.** EIS curves of WS<sub>2</sub>/EP coatings, (a) Bode phaseplots, (b) Bode-modulusplots.

**Table S3.** Electrochemical parameters of WS<sub>2</sub>/EP coatings

WS <sub>2</sub> wt.%	Rs/ Ω cm <sup>2</sup>	Cc/ 10 <sup>-10</sup> Fcm <sup>-2</sup>	Rc/ 10 <sup>10</sup> Ω cm <sup>2</sup>	Cdl/ 10 <sup>-4</sup> Fcm <sup>-2</sup>	Rct/ 10 <sup>6</sup> Ω cm <sup>2</sup>
0	25.4 ± 3.4	98.9 ± 7.8	3.3 ± 0.4 × 10 <sup>-5</sup>	8.76 ± 0.35	3.56 ± 0.33-
0.1	16.5 ± 1.5	13.3 ± 2.5	1.2 ± 0.11	-	-
0.2	17.5 ± 2.2	9.2 ± 0.7	2.8 ± 0.46	-	-
0.3	23.4 ± 3.5	8.6 ± 0.5	1.45 ± 0.23	-	-
0.4	22.4 ± 2.9	8.0 ± 0.6	8.6 ± 0.33	-	-
0.5	19.4 ± 3.4	6.9 ± 0.3	8.9 ± 0.43	-	-
1.0	18.9 ± 2.5	6.5 ± 0.2	9.1 ± 0.29	-	-

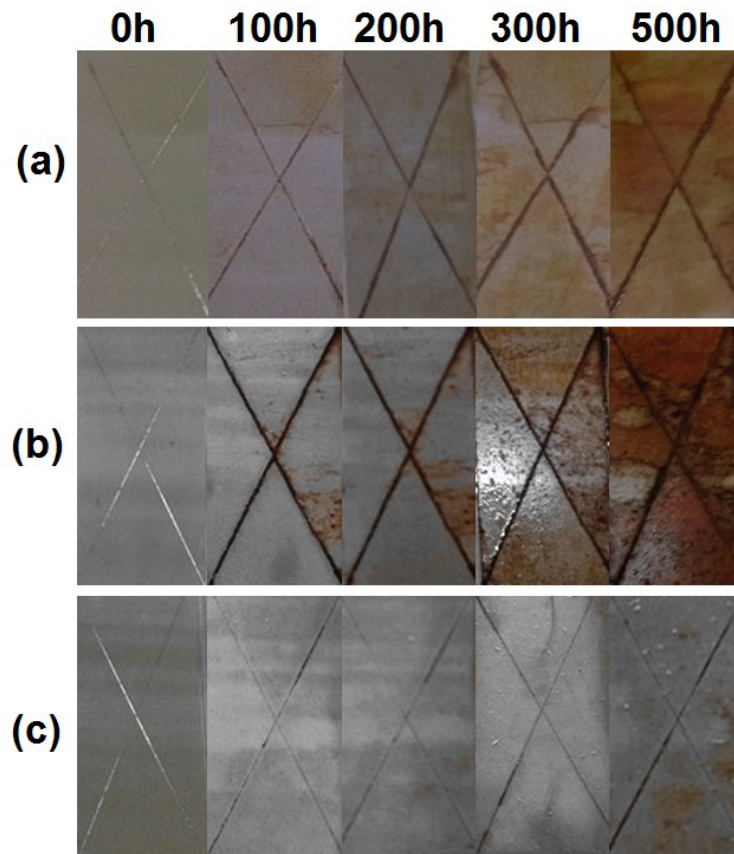


**Figure S6.** EIS curves of GNSs/EP coatings, (a) Bode phaseplots, (b) Bode-modulusplots.

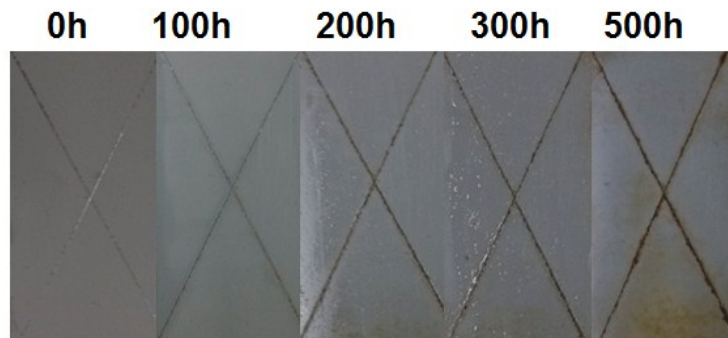
**Table S4.** Electrochemical parameters of GNSs/EP coatings

GNSs wt. %	$R_s / \Omega \text{ cm}^2$	$C_c / 10^{-10} \text{ F cm}^{-2}$	$R_c / 10^{10} \Omega \text{ cm}^2$	$C_{dl} / 10^{-4} \text{ F cm}^{-2}$	$R_{ct} / 10^6 \Omega \text{ cm}^2$
0	$25.4 \pm 3.4$	$98.9 \pm 7.8$	$3.3 \pm 0.4 \times 10^{-5}$	$8.76 \pm 0.35$	$3.56 \pm 0.33$
0.1	$17.9 \pm 3.8$	$27.3 \pm 3.7$	$7.8 \pm 0.38 \times 10^{-3}$	-	-
0.2	$23.3 \pm 2.3$	$7.4 \pm 2.3$	$9.7 \pm 0.43 \times 10^{-3}$	-	-
0.3	$28.2 \pm 1.1$	$7.3 \pm 3.7$	$8.4 \pm 0.45 \times 10^{-2}$	-	-
0.4	$17.2 \pm 2.5$	$6.9 \pm 2.9$	$1.7 \pm 0.28$	-	-
0.5	$23.4 \pm 3.7$	$6.5 \pm 2.6$	$2.3 \pm 0.33$	-	-
1.0	$22.3 \pm 3.5$	$6.8 \pm 2.7$	$2.7 \pm 0.41$	-	-





**Figure S7.** The neutral salt spray tests of NEP (a), 1.0 wt.% GNSs/EP (b), and 1.0 wt.% MoS<sub>2</sub>/EP (c), respectively.



**Figure S8.** The neutral salt spray tests of 1.0 wt.% WS<sub>2</sub>/EP.